MICROWAVE POWER GaN MMIC DIE

MICROWAVE SEMICONDUCTOR TECHNICAL DATA

FEATURES

- ·X-BAND 3-STAGE POWER AMPLIFIER
- ·HIGH POWER

Pout= 44.0dBm(Typ.) at 9.0GHz to 10.0GHz

·HIGH GAIN

GL= 30dB(Typ.)

·HIGH EFFICIENCY

PAE= 45%(Typ.)

·PULSE OPERATION

Pulse width=100µs, Duty cycle=10%

RF PERFORMANCE SPECIFICATIONS ($Ta=25^{\circ}C$)

CHARACTERISTICS	SYMBOL	CONDITIONS	UNIT	MIN.	TYP.	MAX.
Peak Output Power *1	Pout	VDD = 30V IDDset= 0.90A @Pin= 22dBm *1 f= 9.0 to 10.0GHz *2 f= 8.0 to 11.0GHz	dBm	_	44.0	
Peak Output Power *2	Pout		dBm	_	43.0	_
Drain Current	IDD		А	_	_	2.5
Power Added Efficiency	ηadd		%	_	45	
Linear Gain	GL	@Pin= 0dBm	dB		28	

ABSOLUTE MAXIMUM RATINGS (Ta= 25°C)

CHARACTERISTICS	SYMBOL	UNIT	RATING
Drain- Source Voltage	VDD	V	35
Gate- Source Voltage	VGG	V	-4
Drain Current	IDD	A	TBD
Case Temperature	Тс	°C	-40 to +90
Input Power	Pin	dBm	TBD

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Preliminary

JS9U30-AS

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MECHANICAL INFORMATION

ROWAVE SEMICONDUCTOR TECHNICAL DATA



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TYPICAL RF PERFORMANCE

·Pout , PAE vs. Frequency

VDD= 30 V (pulsed), IDDset= 0.90 A, Pin = 22dBm, PW = 100µs, Duty = 10%, Ta= +25°C,

On wafer measurement





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APPLICATION CIRCUIT



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STORAGE ENVIRONMENT

Three months under the following conditions -temperature : 20°C to 27°C -atmosphere: in dry nitrogen

RECOMMENDED ASSEMBLY METHODS

- · Vacuum pencils and/or vacuum collets are the preferred methods of pick up.
- · Use AuSn (80/20) solder and limit exposure to temperatures above 300 °C to 3 4 minutes, maximum.
- · Devices must be stored in a dry nitrogen atmosphere.
- · Thermosonic ball or wedge bonding are the preferred connection methods.
- · 20-micron gold wire must be used for connections.

RECOMMENDED BIASING PROCEDURES

Bias Up Procedure

- 1. Set IDD limit to 3.0 A, IGG limit to 15 mA
- 2. Set VGG to -5.0 V
- 3. Set VDD +30 V
- 4. Adjust VG more positive until IDQ = 0.90 A (VGG ~ -2.1 V Typical)
- 5. Apply RF signal

Bias Down Procedure

- 1. Turn off RF signal
- 2. Reduce VGG to -5.0 V. Ensure IDQ ~ 0 mA
- 3. Set VDD to 0 V
- 4. Turn off VDD supply
- 5. Turn off VGG supply

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